

Our Docket No: 42P10923

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)	
)	
Donghui Lu)	Examiner:
)	
Application No: 10/811,591)	Art Unit:
)	
Filed: March 29, 2004)	Confirmation No: 2696
)	
For: Enhanced Dielectric Layers Using)	
Sequential Deposition)	
)	

SUPPLEMENTAL AMENDMENT AND
RESPONSE TO NON-COMPLIANT AMENDMENT

Mail Stop Amendment
Commissioner for Patents
P.O Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Notice of Non-Compliant Amendment mailed September 15, 2008, Applicants respectfully request the Examiner to enter the following amendment and to consider the following remark.

CERTIFICATE OF EFS Web

I hereby certify that this correspondence is being submitted electronically via EFS Web on the date shown below to the United States Patent and Trademark Office.

Date of Deposit:	<u>October 3, 2008</u>
Name of Person Mailing Correspondence:	<u>Debbie Casias</u>
<u>/Debbie Casias/</u>	<u>/October 3, 2008/</u>
Signature	Date